PE JC178 RR 9 7004 BE

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application of: Somenath Mitra et al.

Application No.: 10/735,988

Examiner: Not Yet Assigned

Group Art Unit: 3753

Filing Date: December 15, 2003

For: Microfabricated Microconcentrator For Sensors

And Gas Chromatography

INFORMATION DISCLOSURE STATEMENT

Commissioner of Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Applicants respectfully submit this Information Disclosure Statement and a copy of the cited references pursuant to 37 C.F.R. §§ 1.56, 1.97 and 1.98 in order to comply with the duty of disclosure. The enclosed Form PTO-1449 identifies the references of which Applicant is aware.

The Examiner is respectfully requested to consider the references herein and make them of record in the subject application. It is Applicant's position that the references cited pursuant to 37 C.F.R. §§ 1.56, 1.97 and 1.98 are clearly not a bar to allowance of the claims in this application.

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail, in an envelope addressed to: Commissioner for Patents, P.O. Bex 1450 Alexandria, VA 22313-1450, on the date shown below.

Dated: April 15, 2004

Signature:

Print Name: Timothy X, Gibson

Application No.: 10/735,988 Attorney Docket No.: 436/13

The above-captioned application has not yet received a substantive Office Action, and accordingly it is believed that no fee is necessary. However, should the Patent Office determine that a fee is due, the Commissioner is authorized to charge any such fee to Deposit Account No. 11-0223.

Dated: April 15, 2004

Respectfully submitted

Timothy X. Gibson

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FOR EO-149 U.S. DEPARTMENT OF COMMERCE (Rev. 2-32)	ATTORNEY DOCKET NO.: 436/13	APPL. NO.: 10/735,988
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APR 1 9 700 ESTATEMENT BY APPLICANT (Use Several sheets if necessary)	FILING DATE: December 15, 2003	GROUP ART UNIT: 3753
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U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA						

FOREIGN PATENT DOCUMENTS

						TRANSLAT	ЮИ
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	YES	NO
BA							

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*ABSTRACT ONLY

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE (Rev. 2-32) PATENT AND TRADEMARK OFFICE

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(Use several sheets if necessary)

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